

Title (en)

ADDITIVE FOR INHIBITING PHOTOLYTIC DEGRADATION REACTIONS IN AMINOPLASTS

Title (de)

ADDITIV ZUR INHIBIERUNG VON PHOTOLYTISCHEN ABBAUREAKTIONEN IN AMINOPLASTEN

Title (fr)

ADDITIF PERMETTANT D'INHIBER DES REACTIONS DE DEGRADATION PHOTOLYTIQUES DANS DES AMINOPLATES

Publication

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Application

**EP 02799749 A 20021219**

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Abstract (en)

[origin: WO03054083A1] The invention relates to a UV additive for aminoplast resins, to a method for producing a UV additive as well as to uses thereof. Said UV additive is characterised in that it contains soluble sterically-hindered nitroxyl compounds in an aqueous aminoplast precondensate. A UV additive for aminoplast resins with several application forms is thus obtained.

IPC 1-7

**C08L 61/20**; **C08J 5/24**; **C08K 5/3435**

IPC 8 full level

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CPC (source: EP US)

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Citation (search report)

See references of WO 03054083A1

Citation (examination)

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